	Hits	Search Text	DBs
16	3	((hydrophilic\$4 or oleophilic\$4) near16 pattern\$4) and ((hydrophobic\$4 or oleophob\$5) near16 pattern\$4) and ((polymeriz\$7 near12 (activat\$4 or initiat\$4)) and (polymeri\$6 near12 (inactivate or immobiliz\$2 or inert\$4) near12 initiat\$3 near16 (imag\$4 or exposure or illuminat\$4 or irradiat\$4)) and (polymeriz\$5 same graft\$4) and ((substrate or wafer or device) same (polymeriz\$6 near16 (surface or site or active or area or pattern or select\$4) near22 (initiat\$4 or radical)))	US-PGPUB
17	0	430/320.ccls. and ((hydrophilic\$4) or oleophilic\$4) near16 pattern\$4) and ((hydrophobic\$4 or oleophob\$5) near16 pattern\$4) and (polymeriz\$7 near12 (activat\$4 or initiat\$4)) and (polymeri\$6 near12 (immobili\$5 or inactivate) near16 (imag\$4 or exposure or illuminat\$4 or irradiat\$4)) and (polymeriz\$5 same graft\$4) and ((surface pag\$5 active pag\$5	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
18	1	l/nolumerizsh came gratts/1) and	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
19	1	430/324.ccls. and ((hydrophilic\$4) or oleophilic\$4) near16 pattern\$4) and ((hydrophobic\$4 or oleophob\$5) near16 pattern\$4) and (polymeriz\$7 near12 (activat\$4 or initiat\$4)) and (polymeri\$6 near12 (immobili\$5 or inactivate) near16 (imag\$4 or exposure or illuminat\$4 or irradiat\$4)) and (polymeriz\$5 same graft\$4) and (polymeriz\$5 same graft\$4) and ((surfactant or material or (surface near5 active near5 (material or agent))) same (dye or colorant or conductive or metal\$3)) and ((substrate or wafer or device) same (polymeriz\$6 near16 (surface or site or active or area or pattern or select\$4) near22 (initiat\$4 or radical)))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB

Hit	s Search Text	DBs
20 2	near12 inactivate near16 (imag\$4 or exposure or illuminat\$4 or irradiat\$4)) and (polymeriz\$5	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB